

# MNC 2017

*Ramada Plaza Jeju Hotel*

*Jeju, Korea*

*November 6 ~ 9, 2017*

## CONFERENCE SCOPE

**1: Lithography and Related Technologies and Metrology**

- 1.1 : Advanced Photolithography
- 1.2 : Electron and Ion Beam Technologies
- 1.3 : Resist and Directed Self-Assembly

**2: Nanotechnology**

- 2.1 : Nanocarbons
- 2.2 : Nanodevices
- 2.3 : Nanofabrication
- 2.4 : Inorganic Nanomaterials
- 2.5 : Organic Nanomaterials
- 2.6 : Nano Tool

**3: Nanoimprint, Nanoprint and Rising Lithography**

**4: BioMEMS, Lab on a Chip**

**5: Microsystem Technology and MEMS**

## PLENARY SPEAKERS



**Prof. Young Hee Lee**  
Sungkyunkwan Univ., Korea



**Dr. Tatsuhiko Higashiki**  
Toshiba Memory Corp., Japan



**Prof. Sayeef Salahuddin**  
Univ. of California, Berkeley, USA



**Dr. Luigi Colombo**  
Texas Instruments, USA

## COMMITTEE CHAIRS

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*Eun Kyu Kim (Hanyang Univ., Korea)*

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*Jinho Ahn (Hanyang Univ., Korea)*

**Program Committee**

*Sungwoo Hwang (SAIT, Korea)*

*Suk Ho Choi (Kyung Hee Univ., Korea)*

**Accepting Late-news Papers**

*till September 15, 2017*

## CONTACT

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<http://www.mnc2017.org/>



The Korean Physical Society

The Korean Vacuum Society



The Japan Society of Applied Physics



Jeju Convention & Visitors Bureau

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